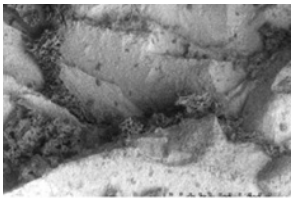
Images of RS9 (*Fraxinus*-scraping) residues

using Hitachi S3500N VP-SEM

The key to the images is in the first two pages of this document.

The images published in this pdf are those that were used in the training portion of the experiment reported in Monnier et al. 2012, *J. Arch. Sci*. For questions, please contact Gilliane Monnier at monni003@umn.edu.

Naming conventions: 'RS' = Residue Study; 'D' = Dorsal side; 'V' = Ventral side; 'a', 'b', etc. = residue label; '25', '50', '115' = magnification used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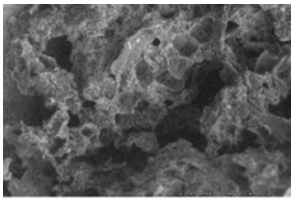
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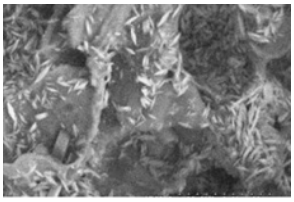
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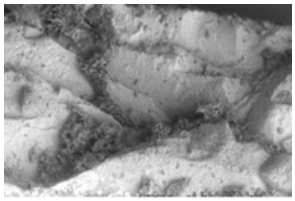
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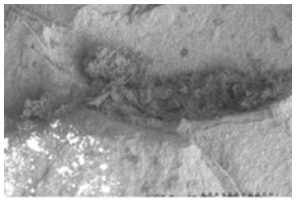
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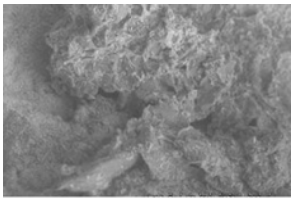
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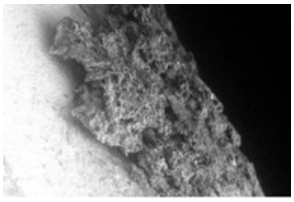
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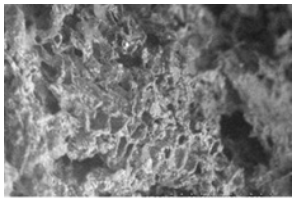
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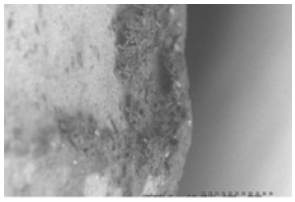
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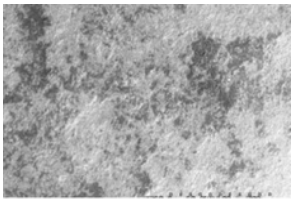
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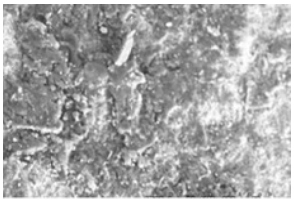
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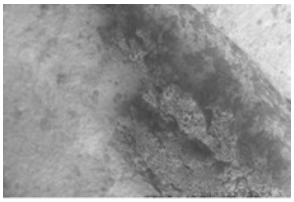
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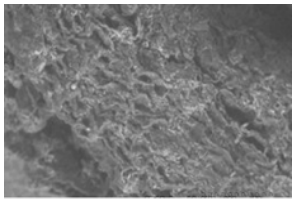
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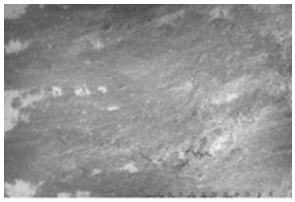
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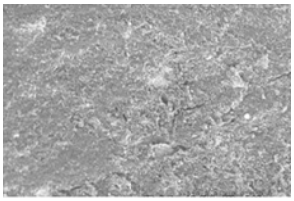
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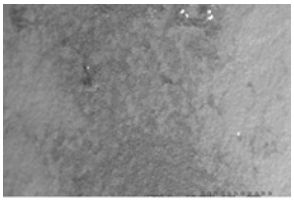
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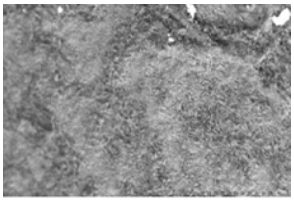
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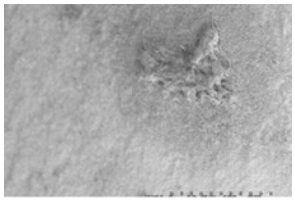
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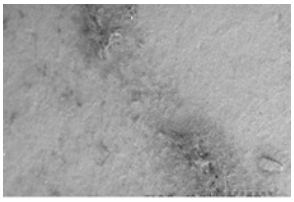
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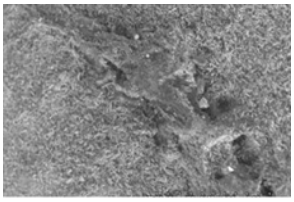
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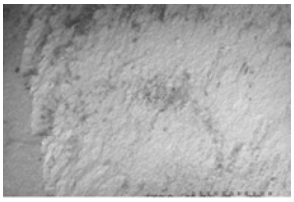
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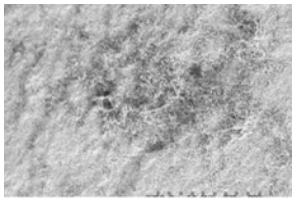
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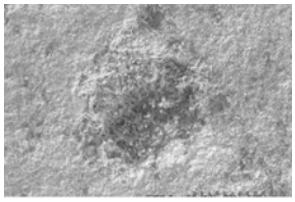
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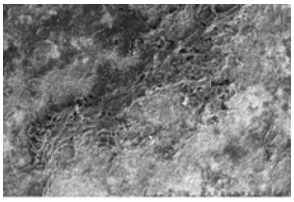
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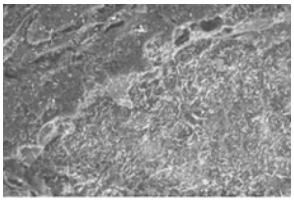
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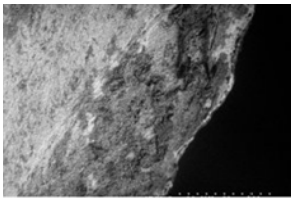
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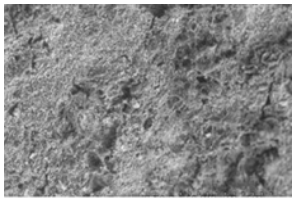
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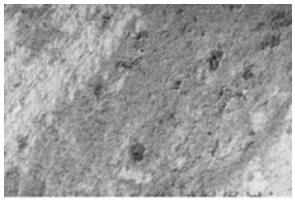
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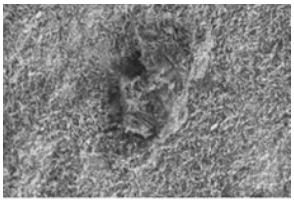
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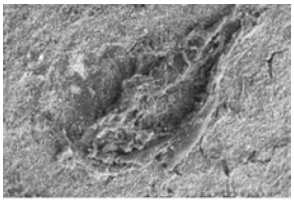
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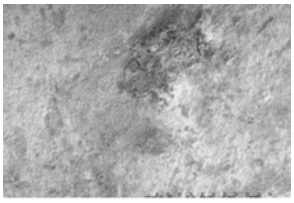
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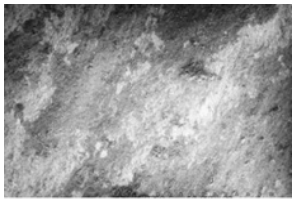
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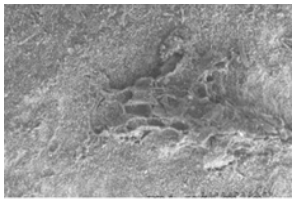
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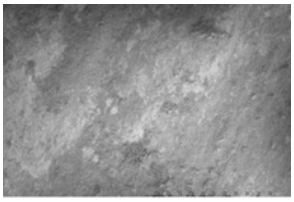

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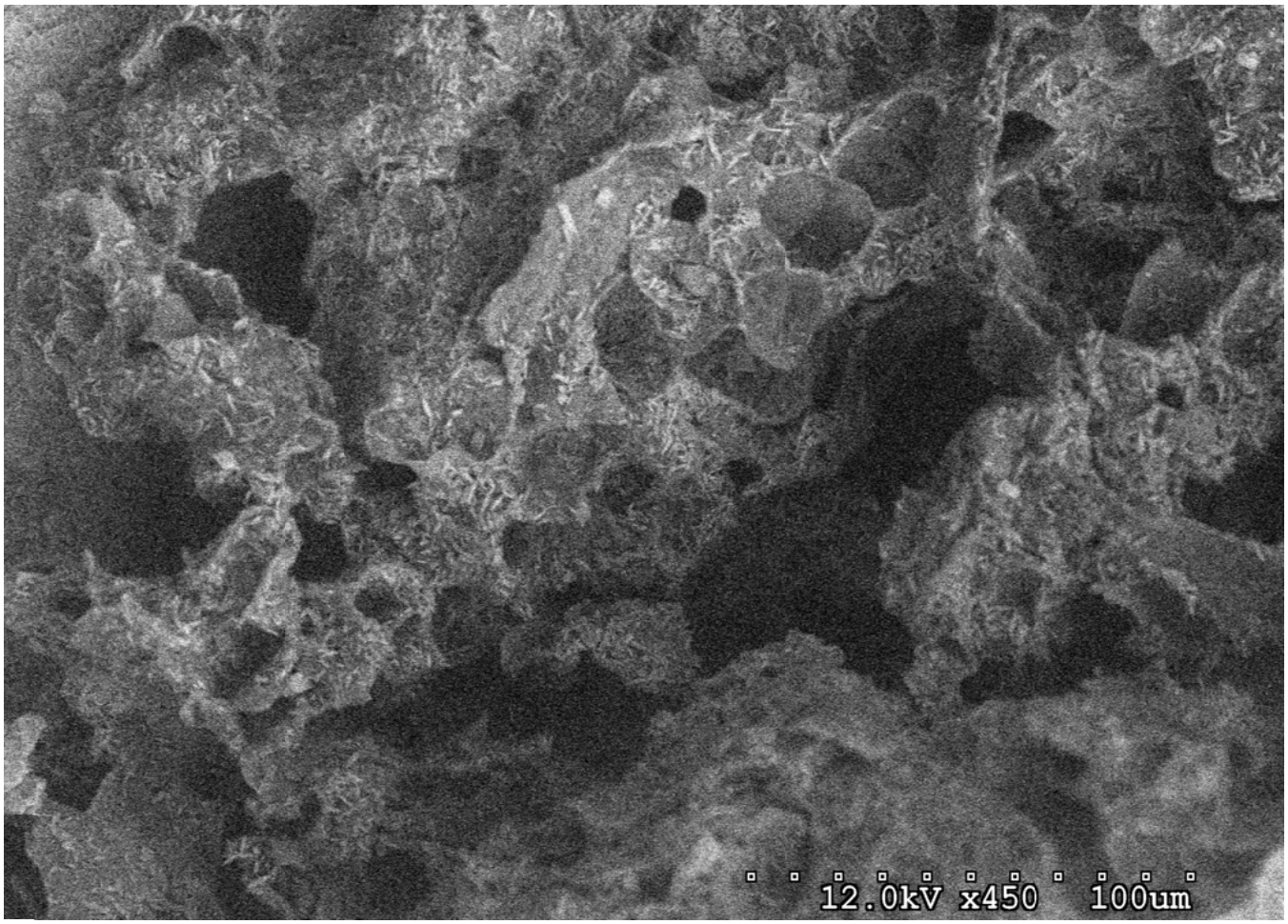
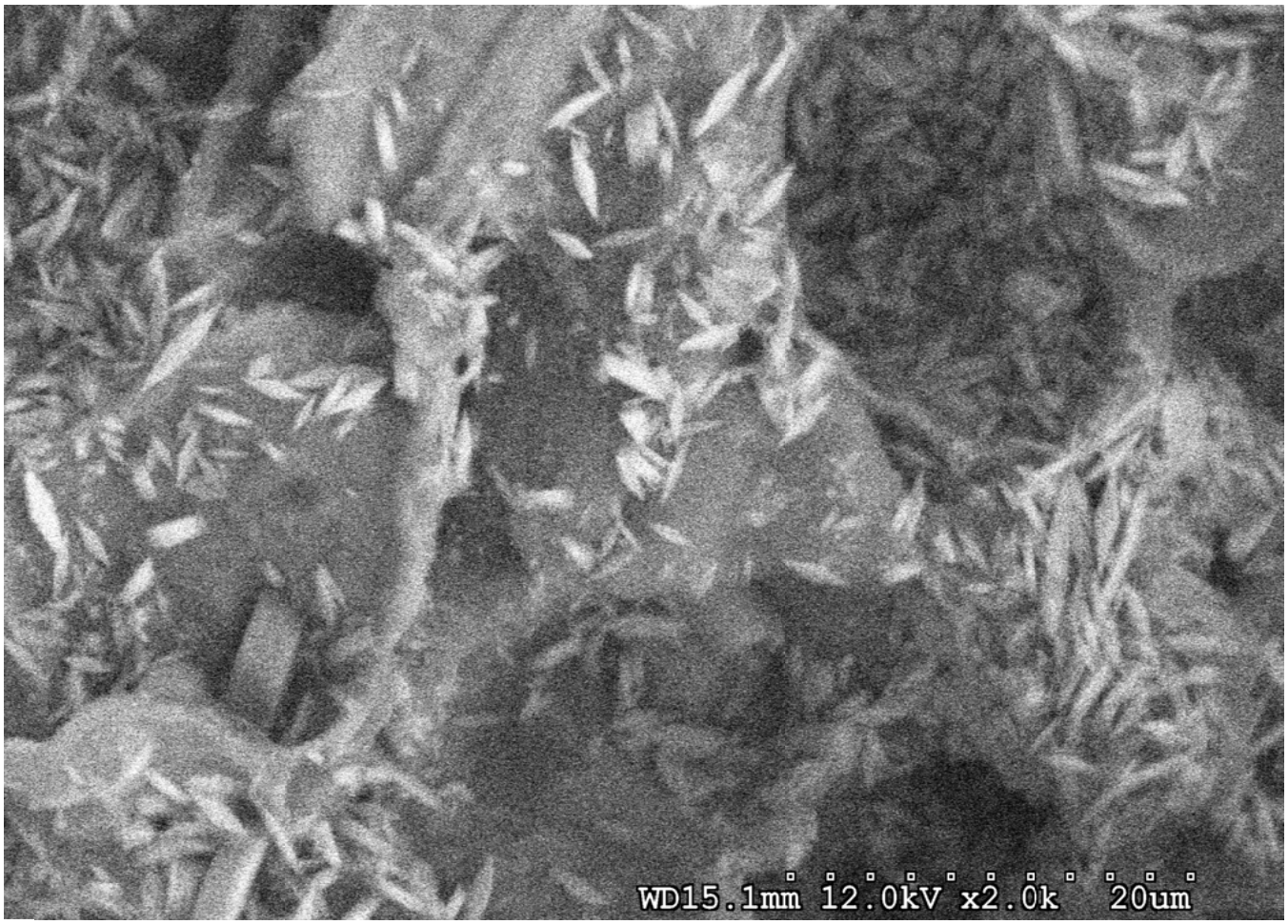
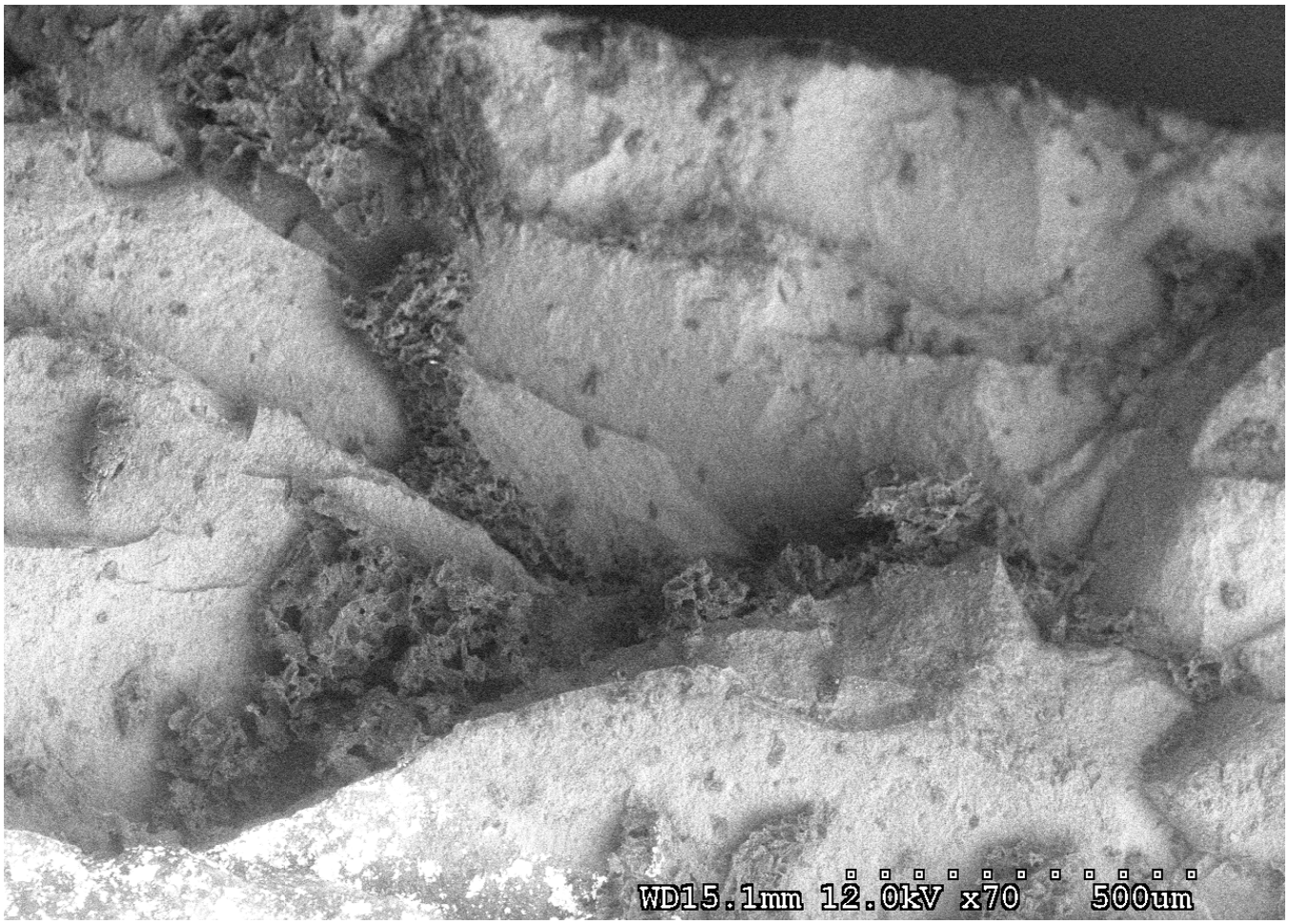
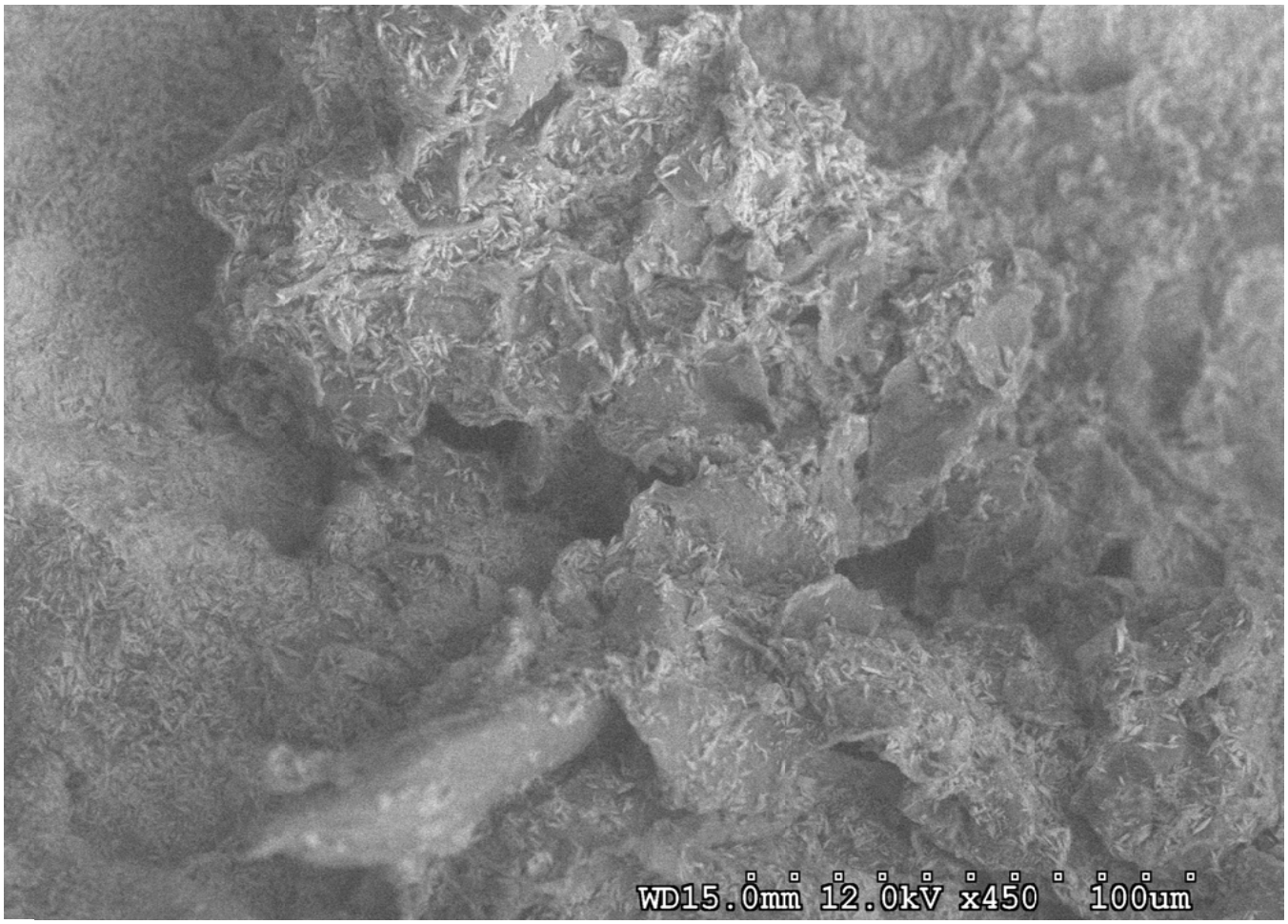
12.0kV x90 500um


12.0kV x450 100um


WD15.1mm 12.0kV x2.0k 20um


WD15.1mm 12.0kV x70 500um

WD16.3mm 12.0kV x120 250um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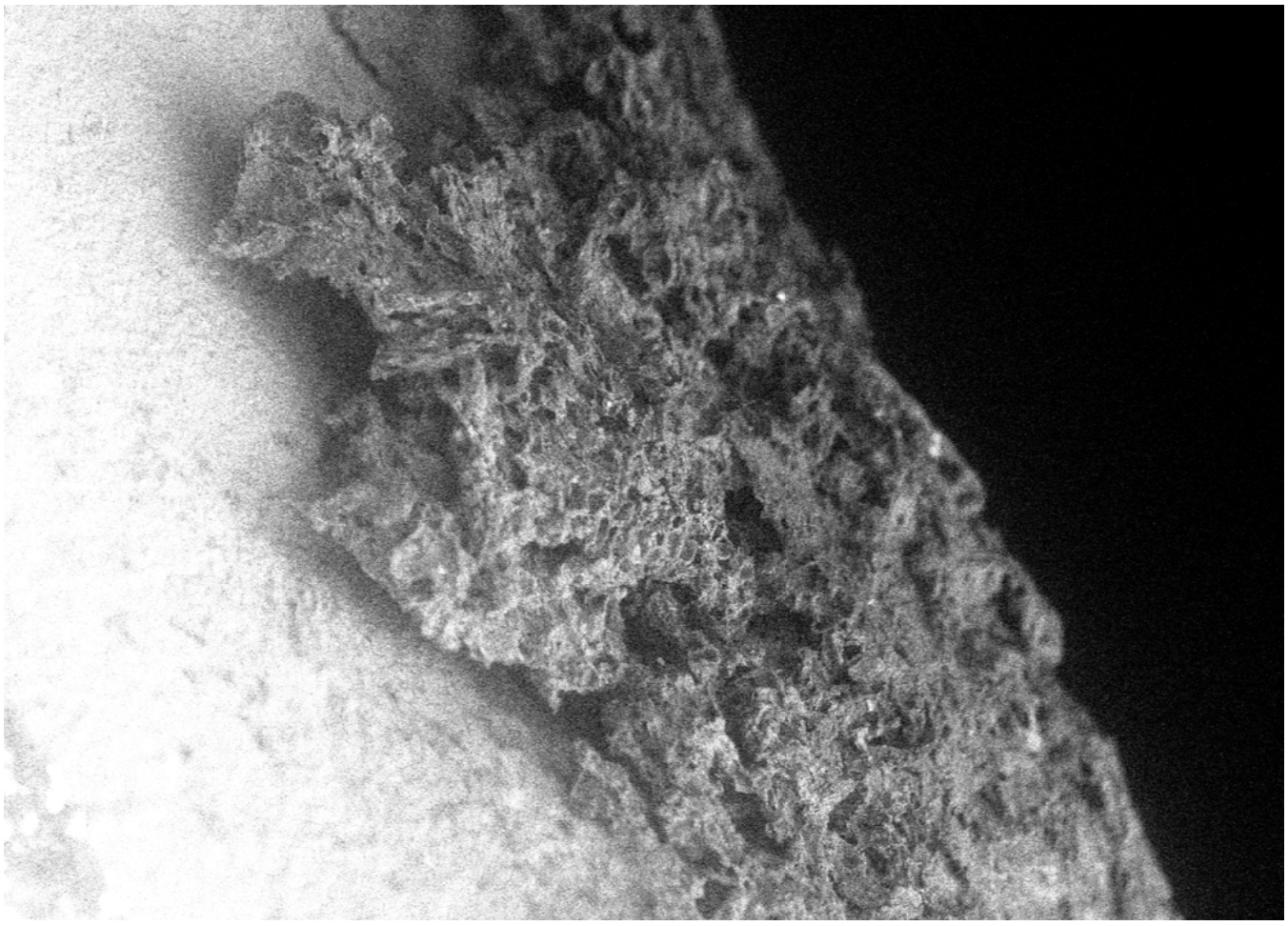
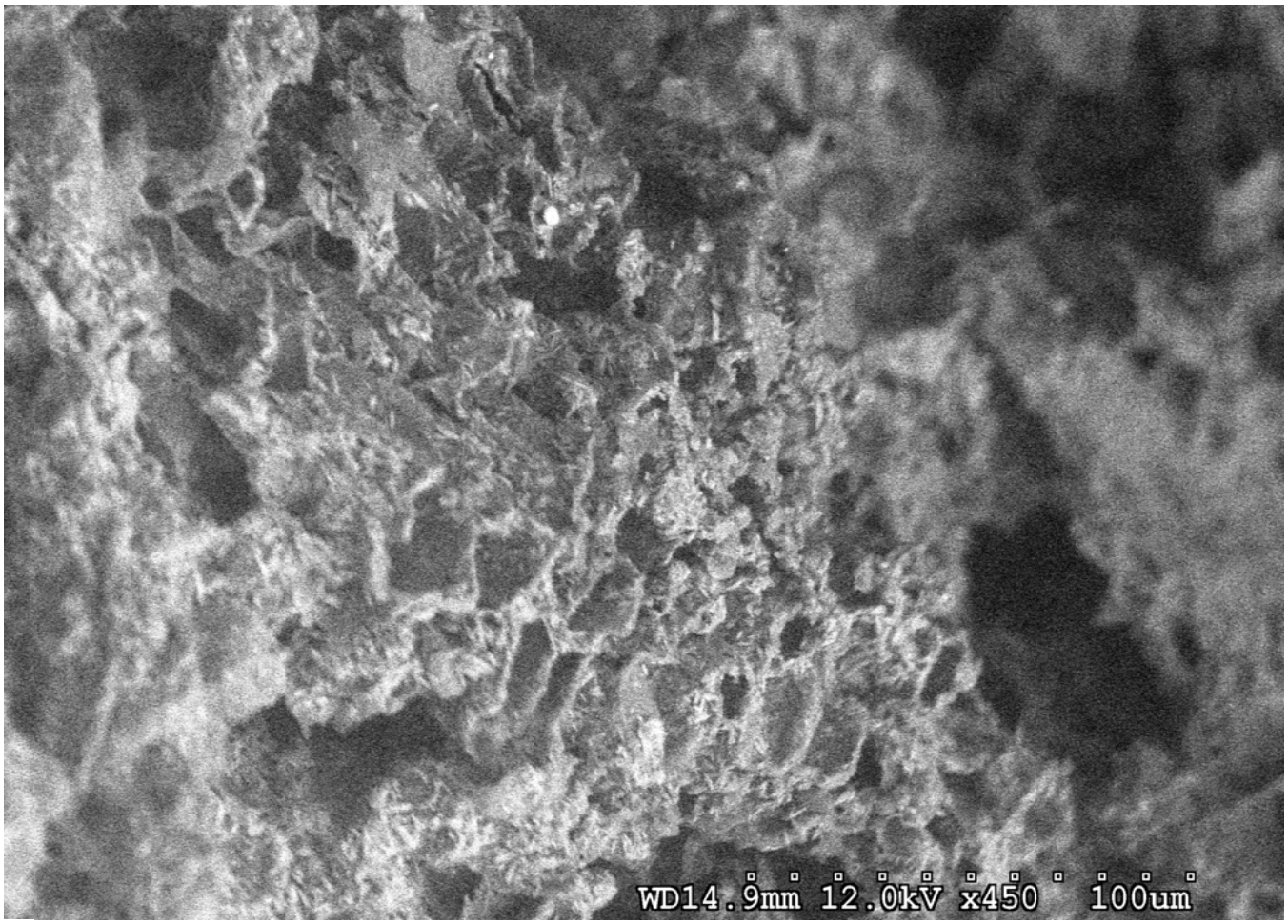
WD15.2mm 12.0kV x150 200um

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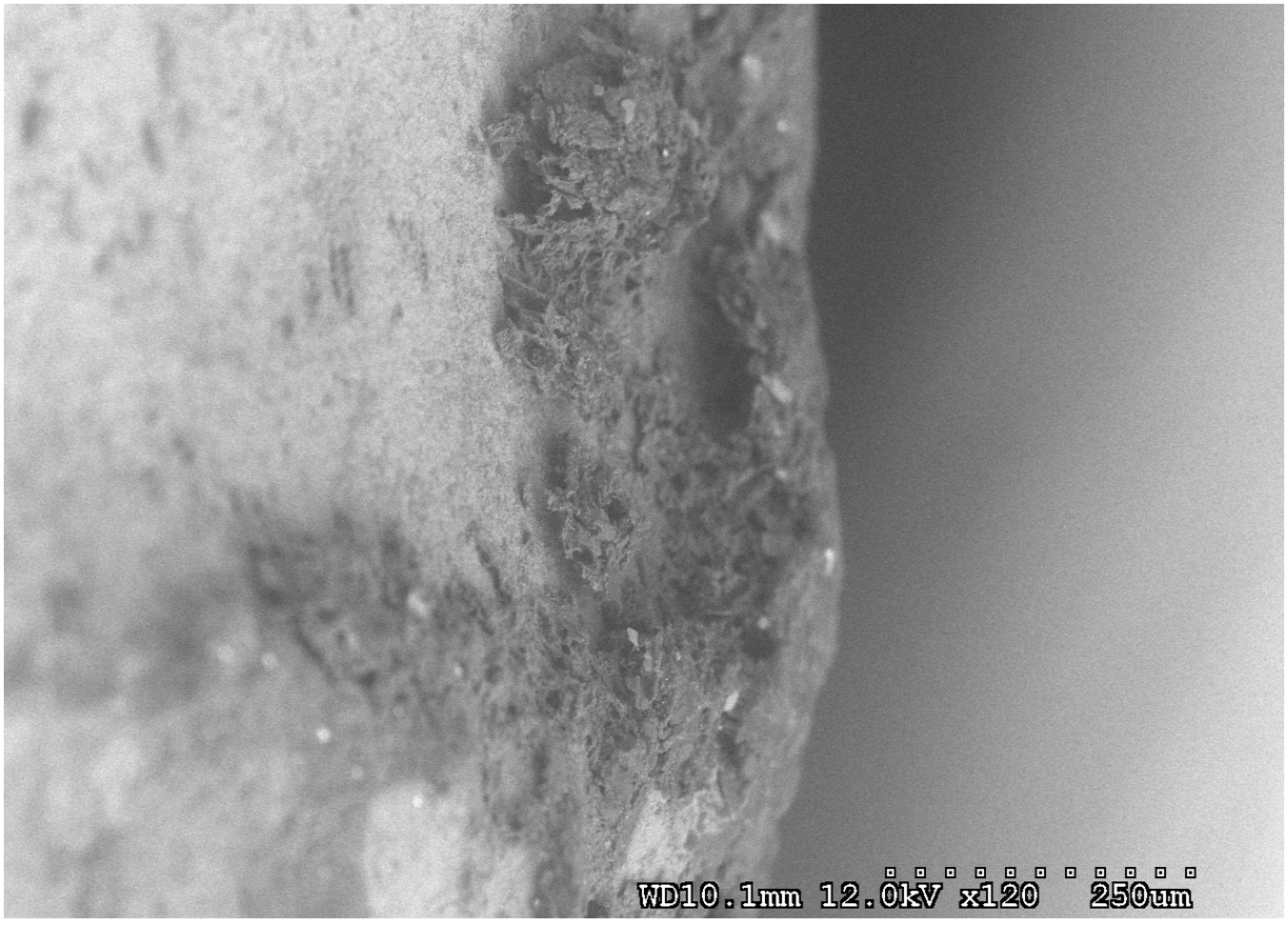
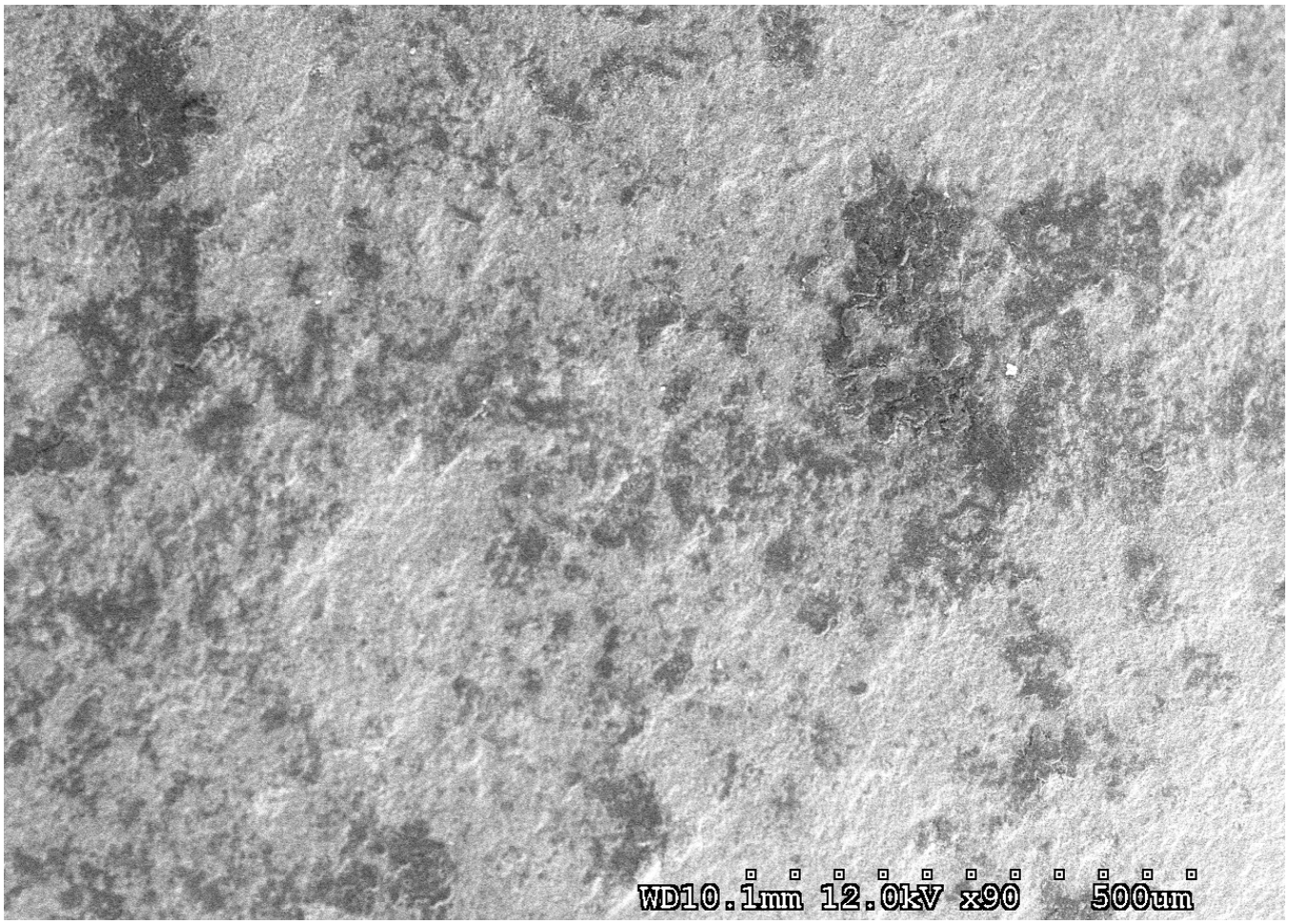

WD10.1mm 12.0kV x120 250um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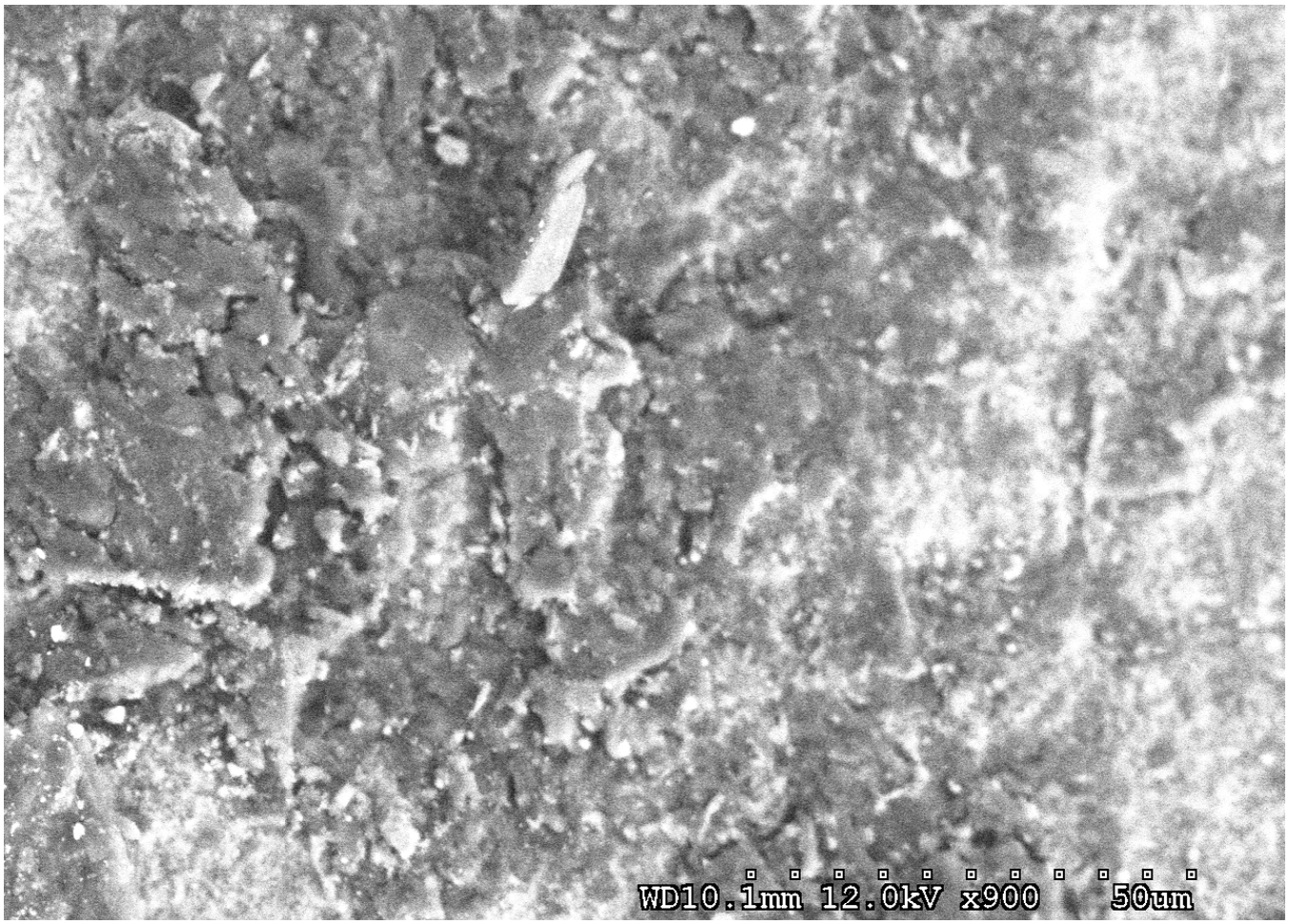
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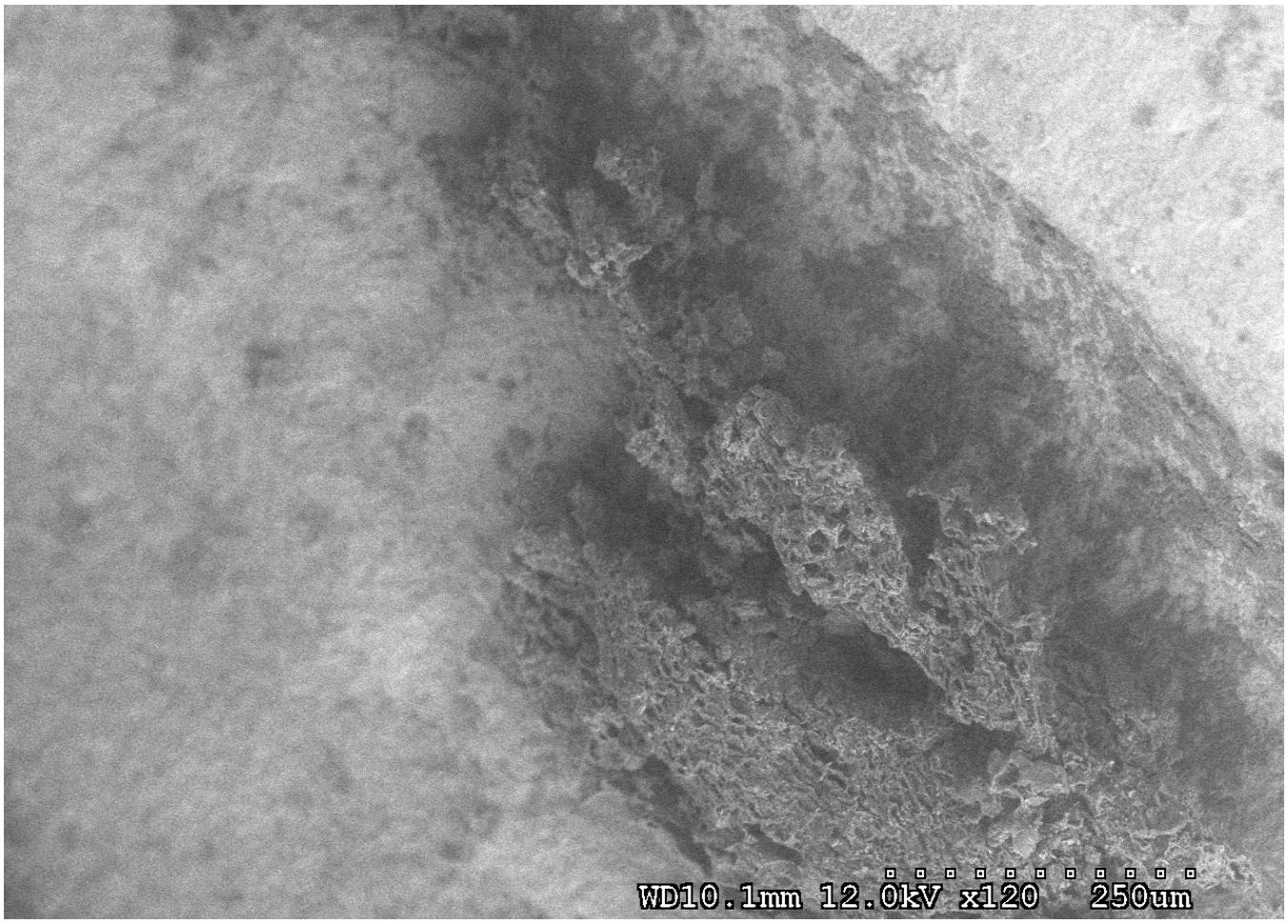
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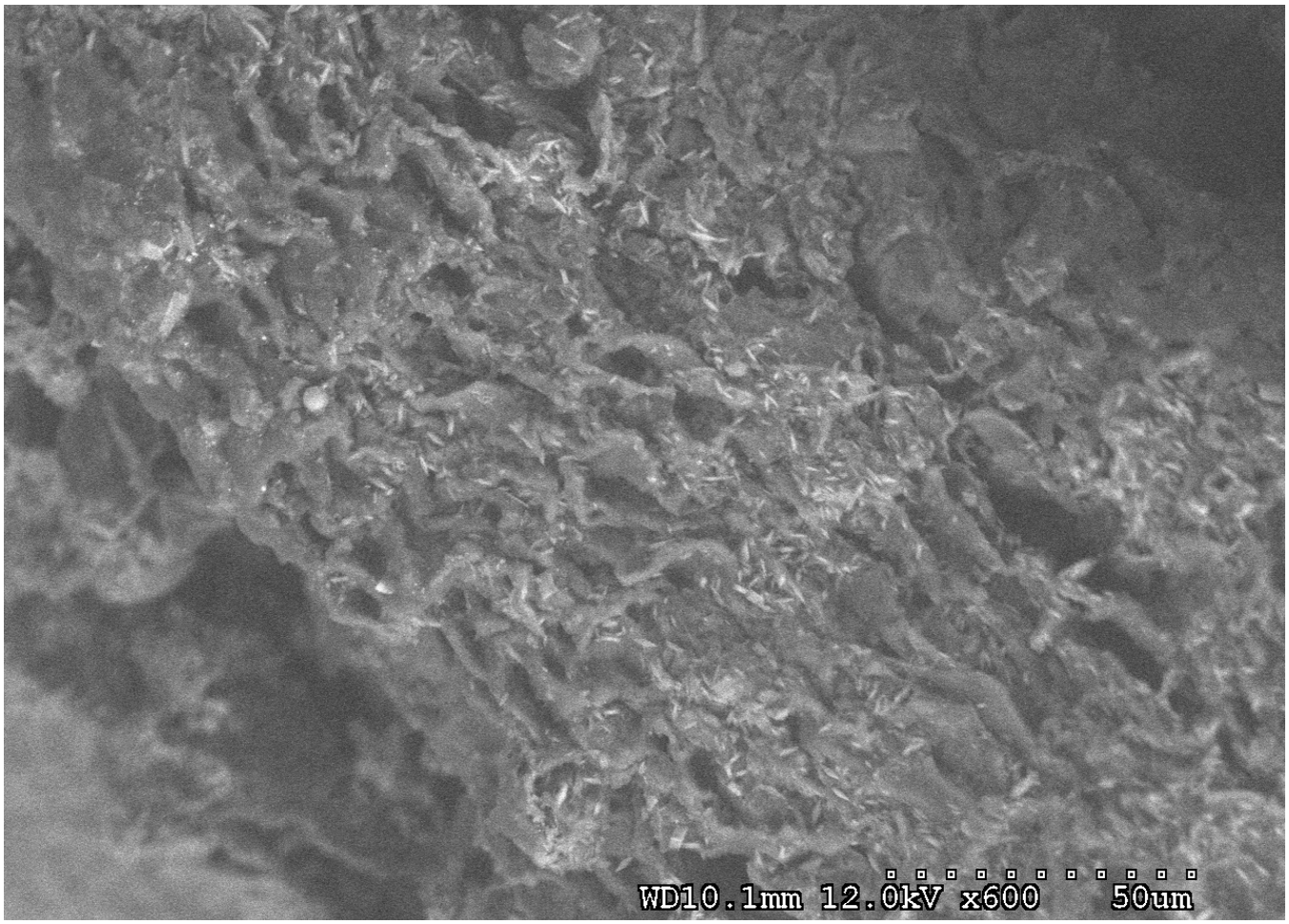
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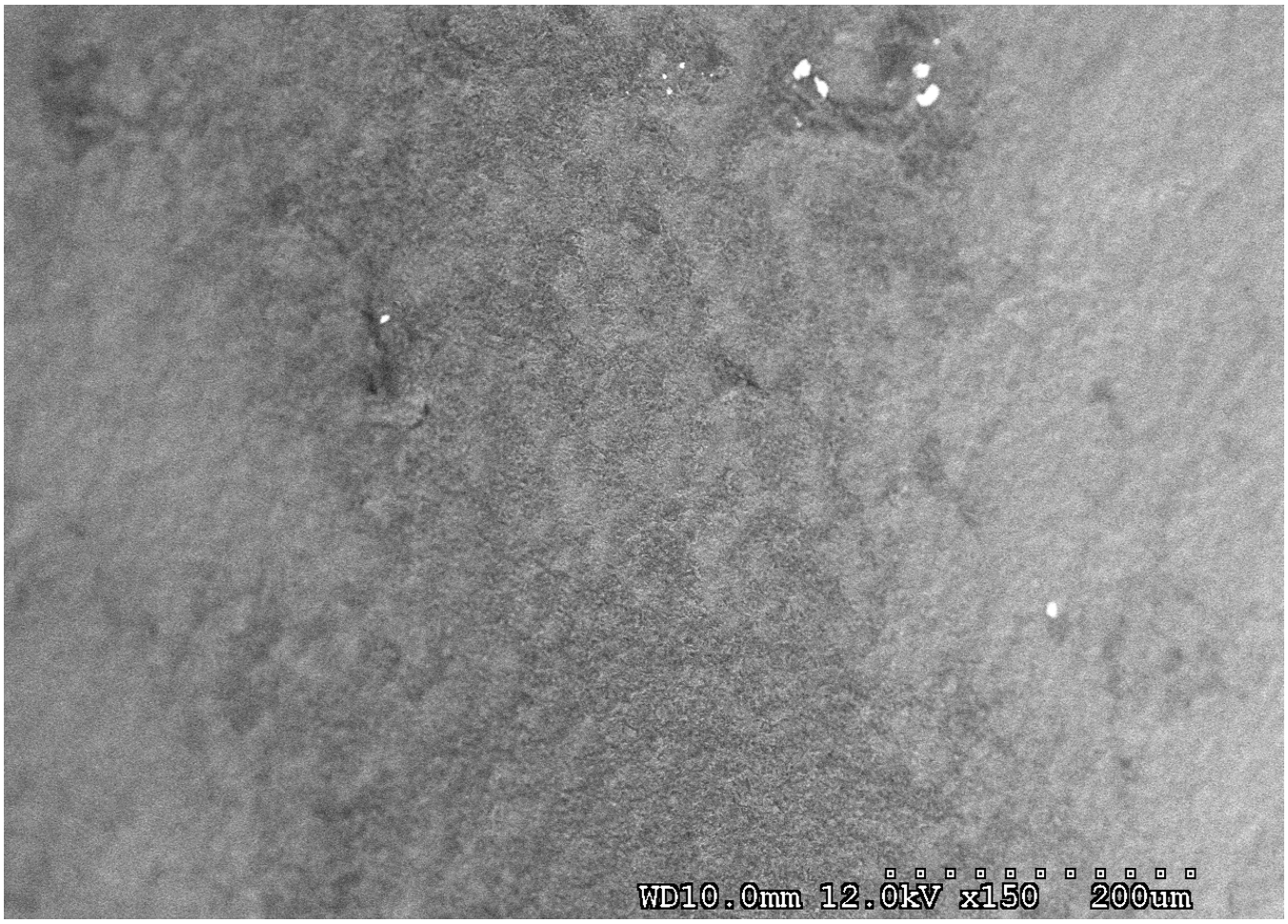
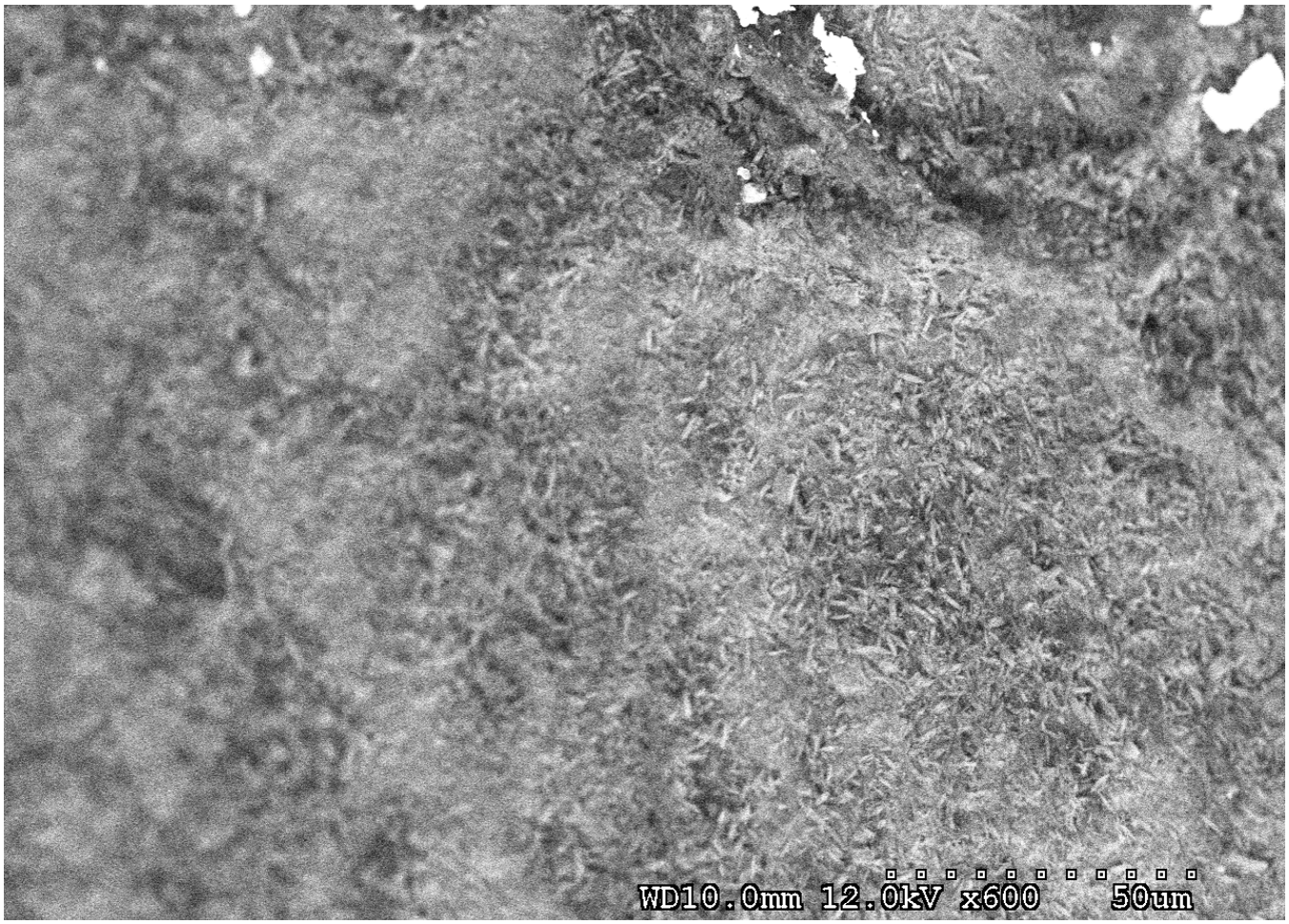
WD 9.5mm 12.0kV x50 1mm

WD 9.5mm 12.0kV x400 100um


WD10.0mm 12.0kV x150 200um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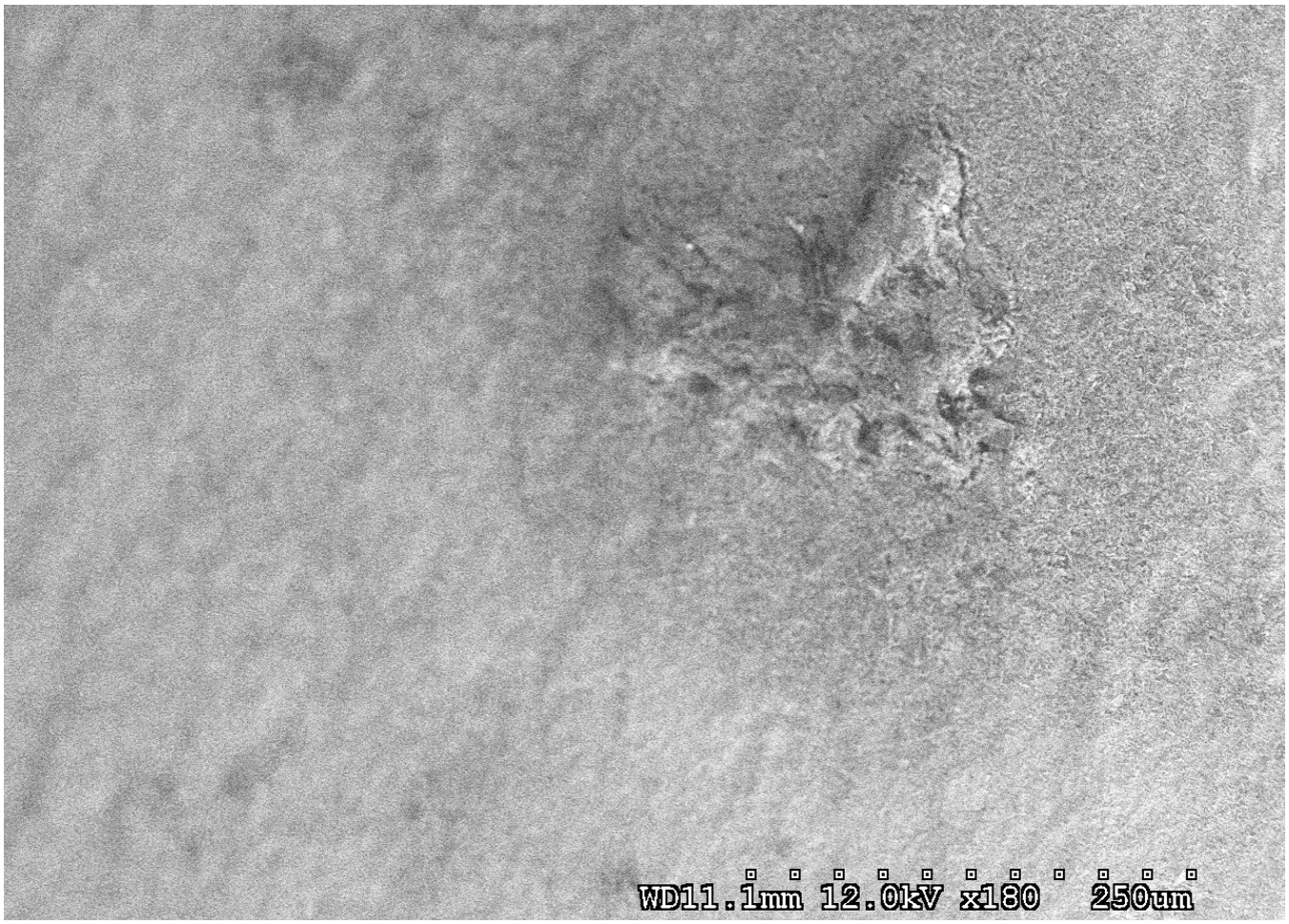
WD 9.9mm 12.0kV x1.5k 20um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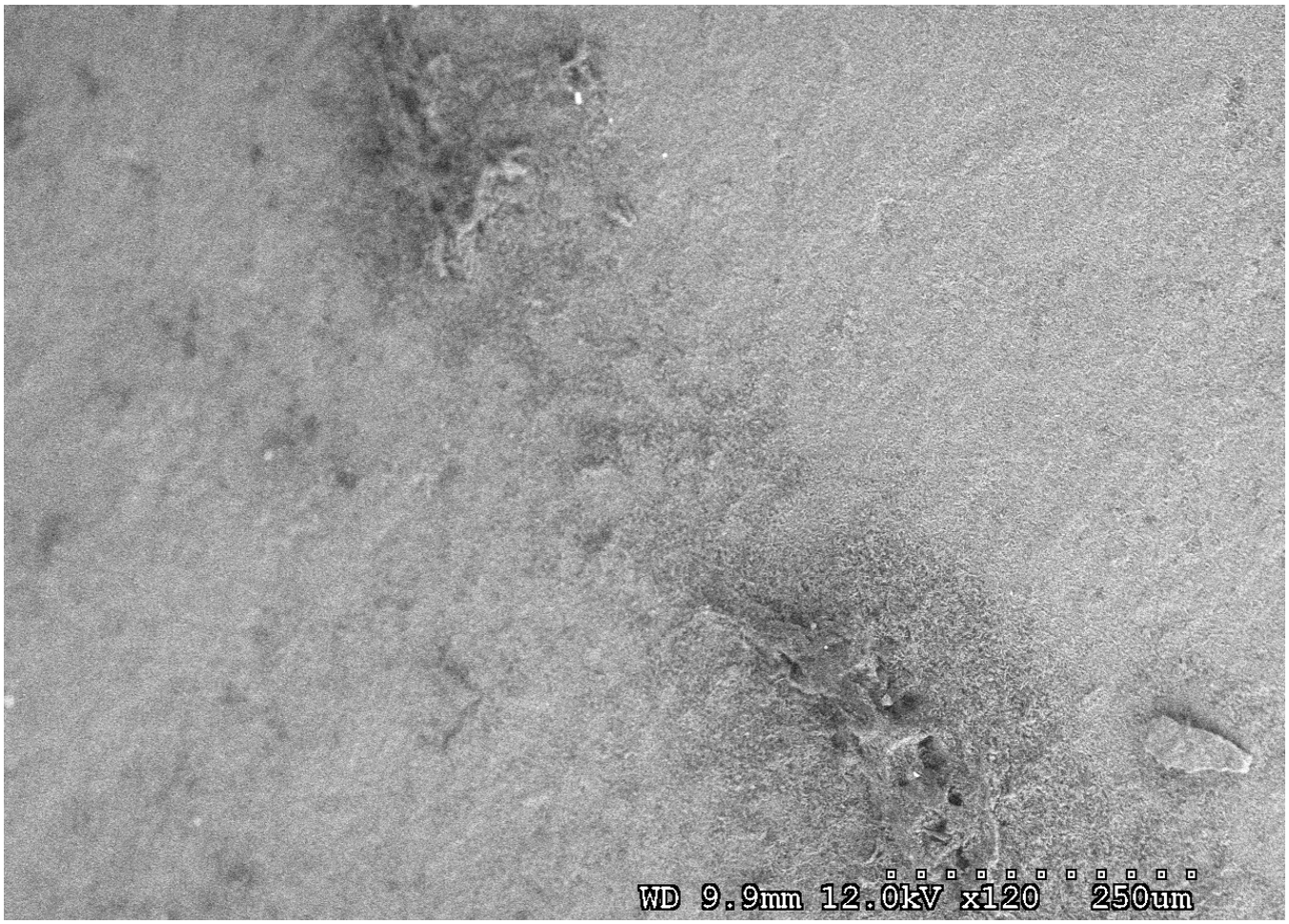
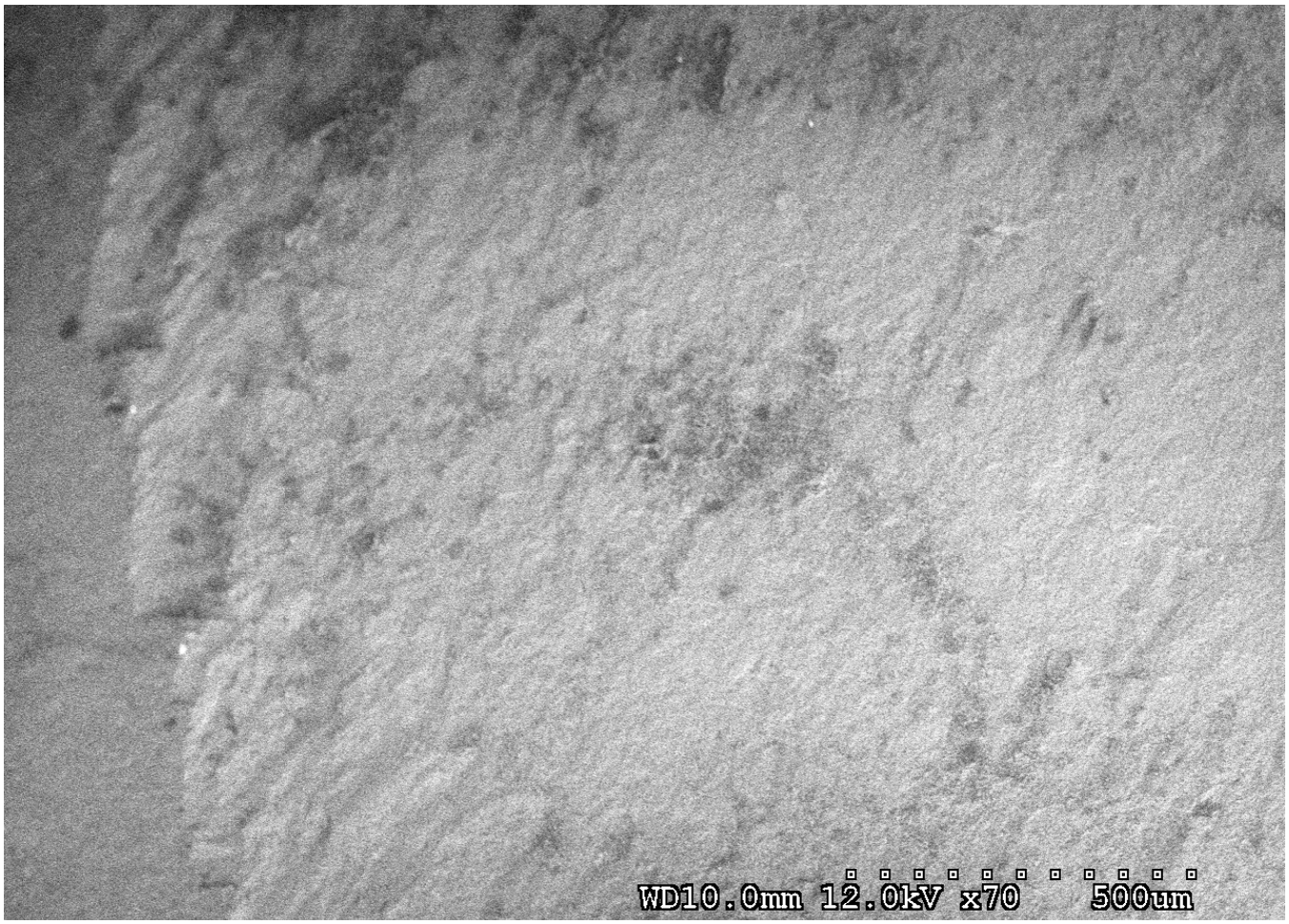
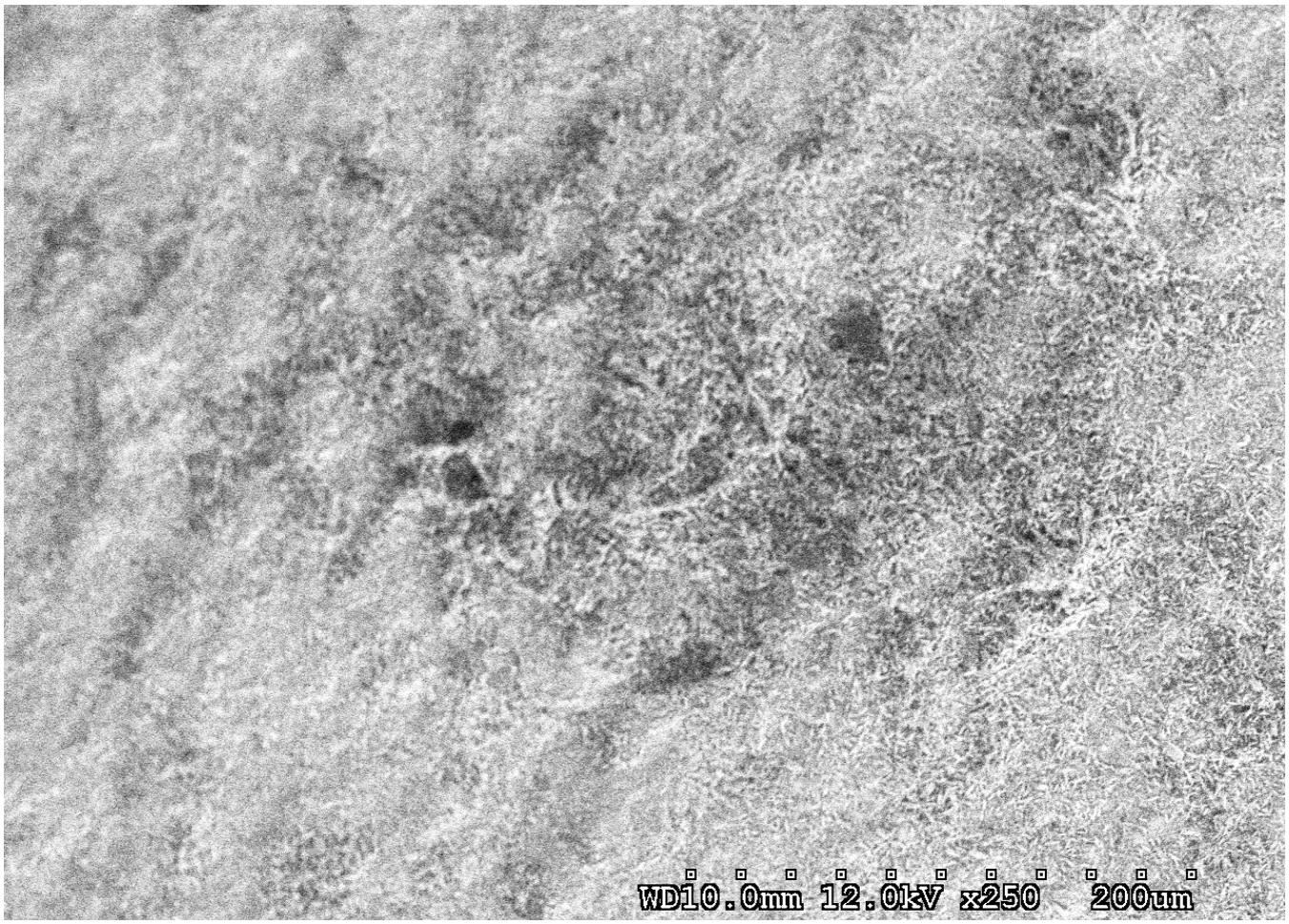
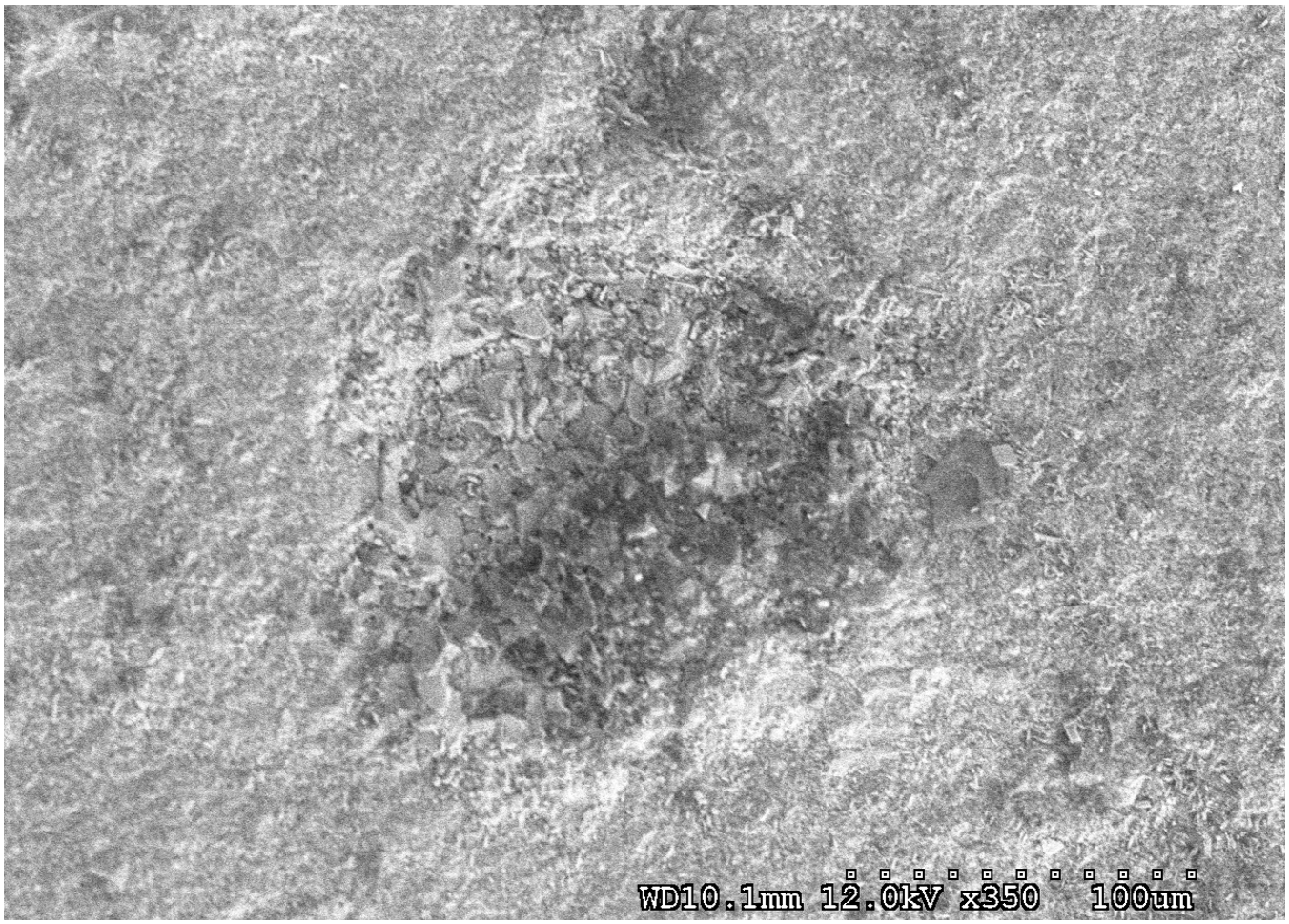
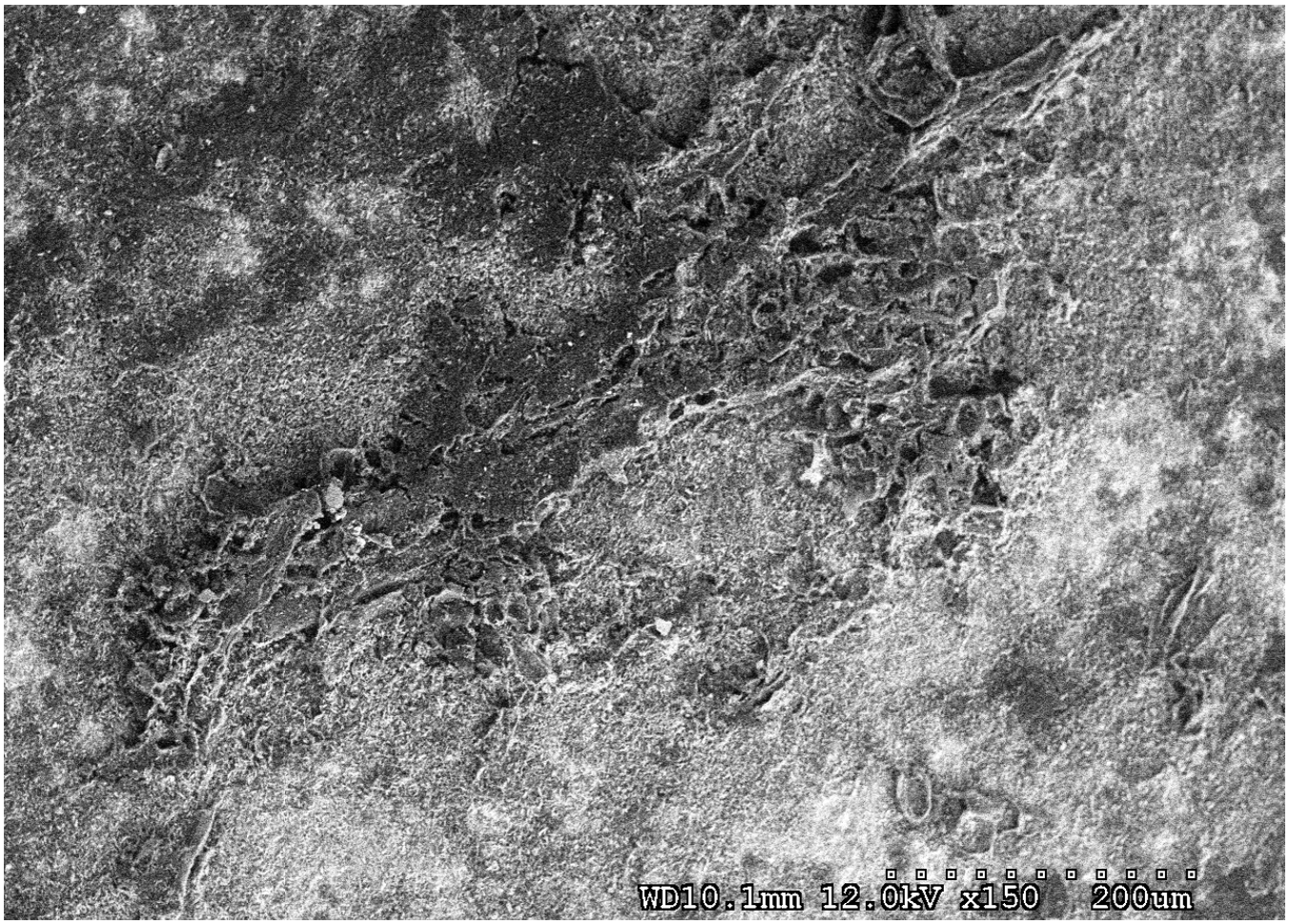

WD 9.9mm 12.0kV x120 250um

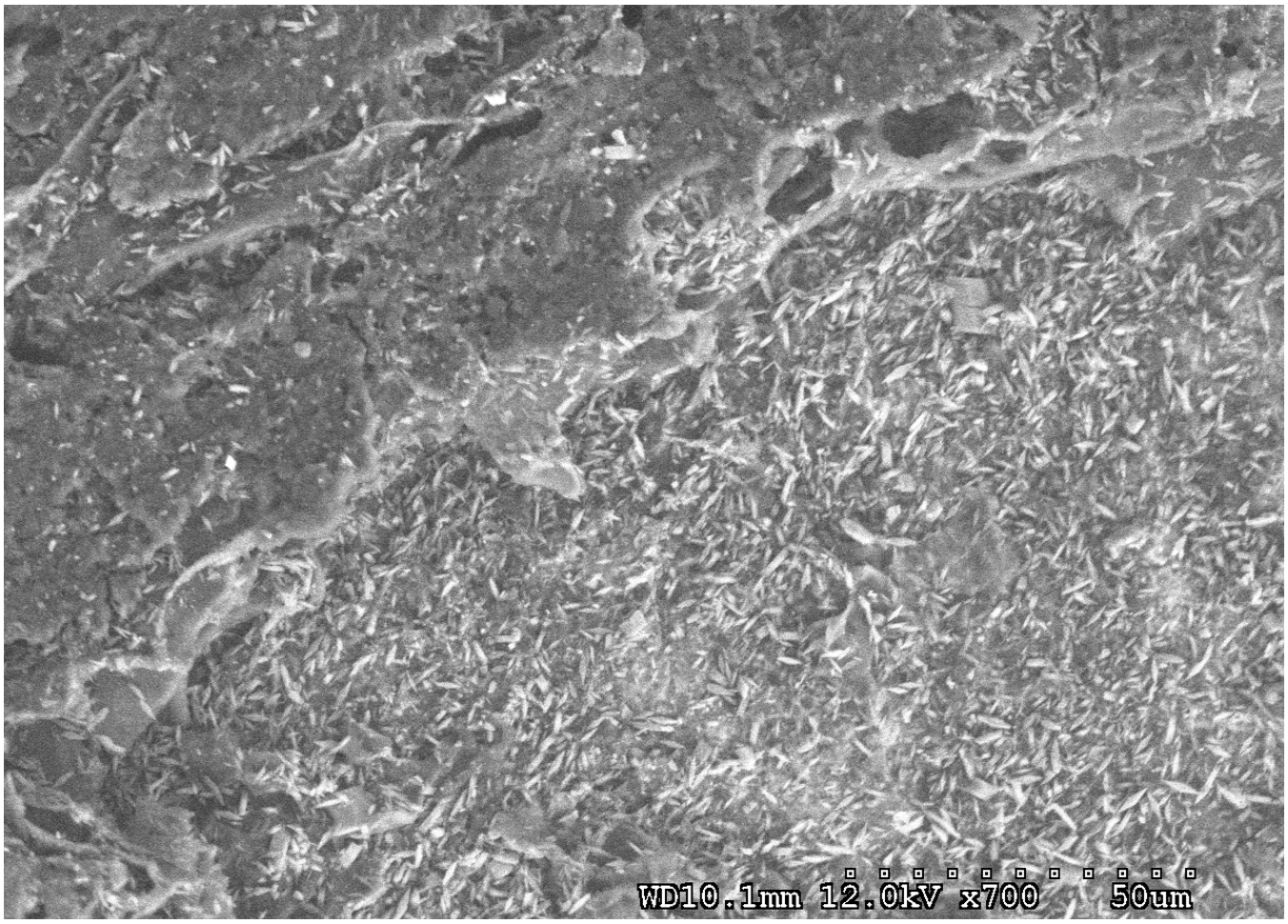
WD10.0mm 12.0kV x500 100um

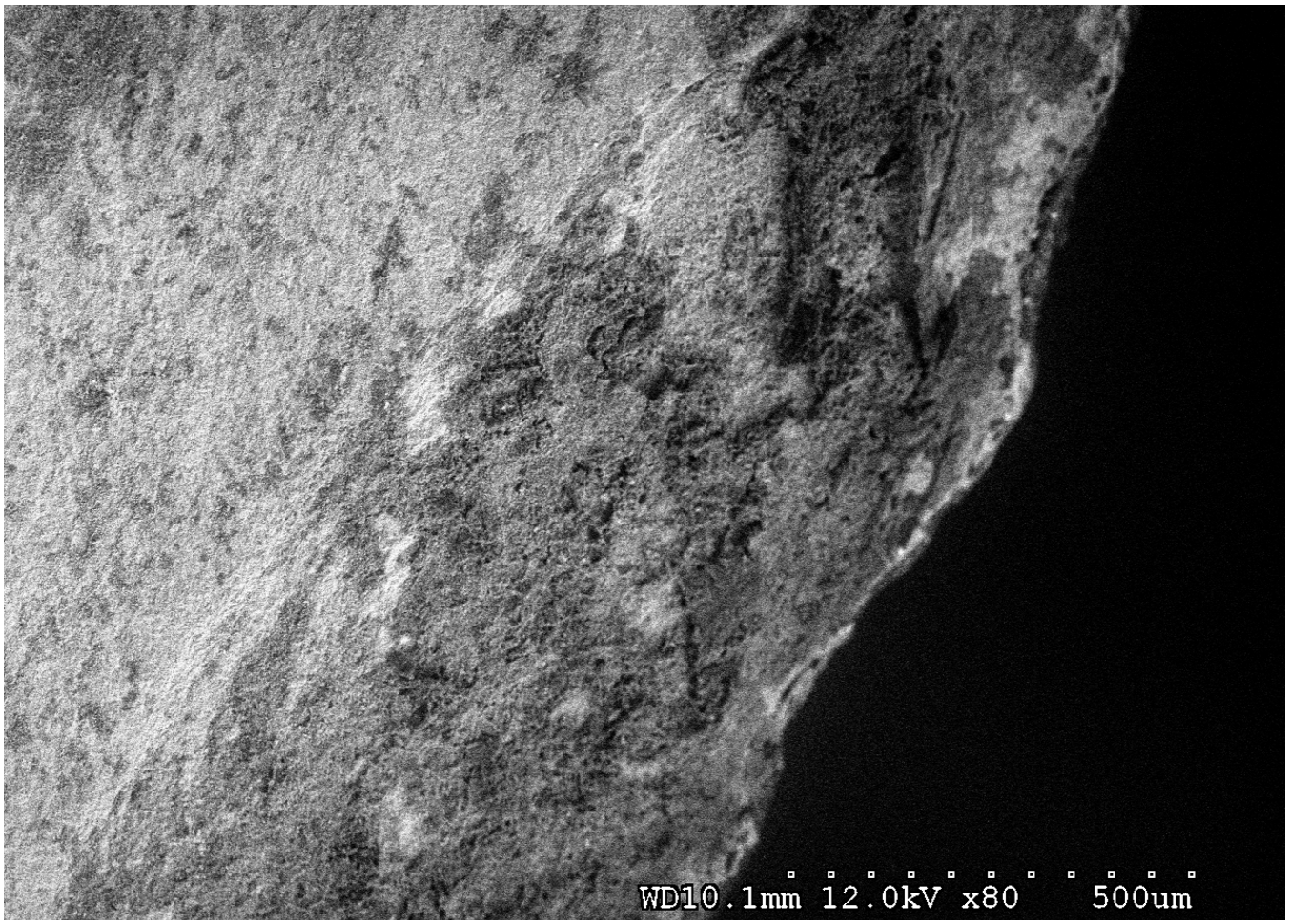

WD10.0mm 12.0kV x70 500um

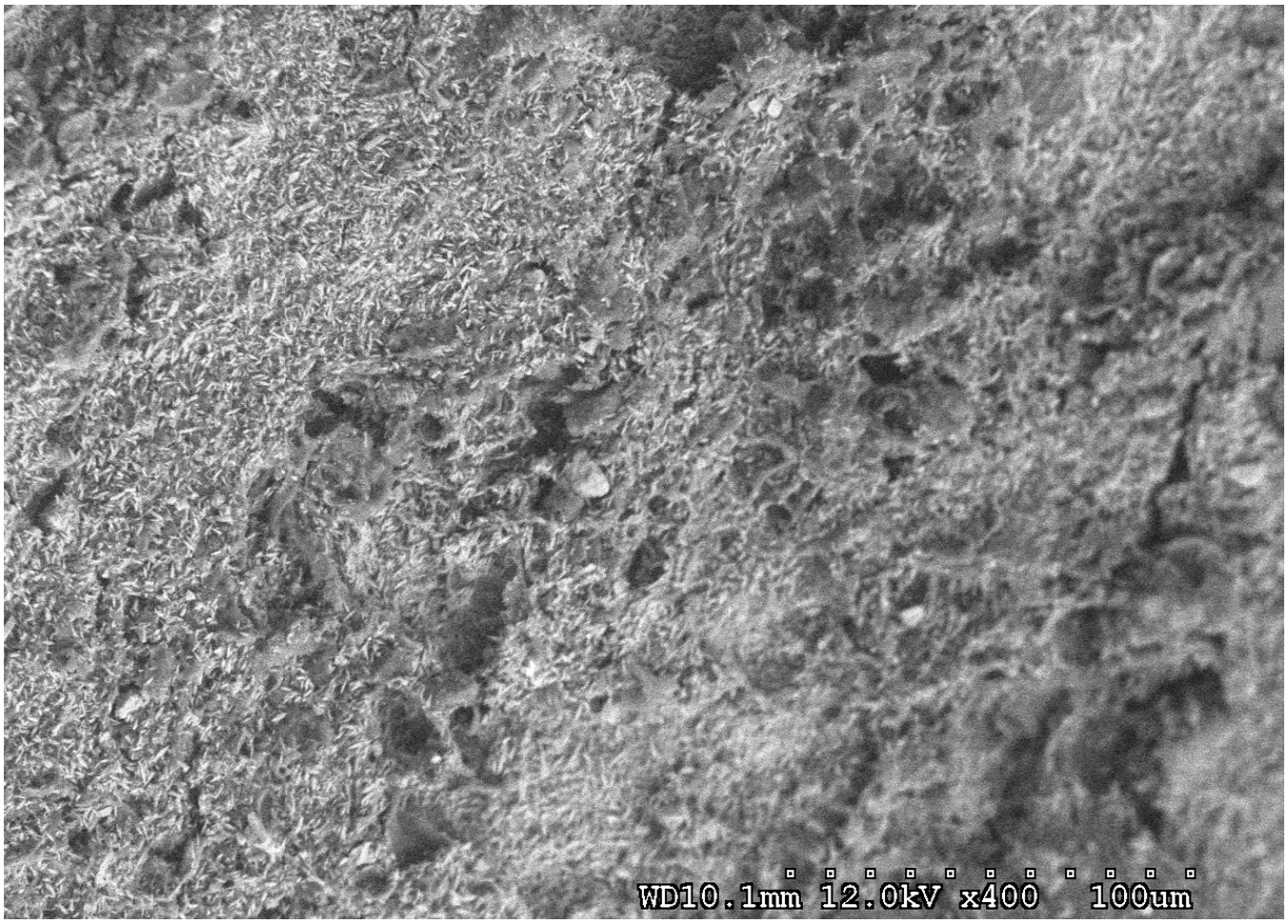

WD10.0mm 12.0kV x250 200um

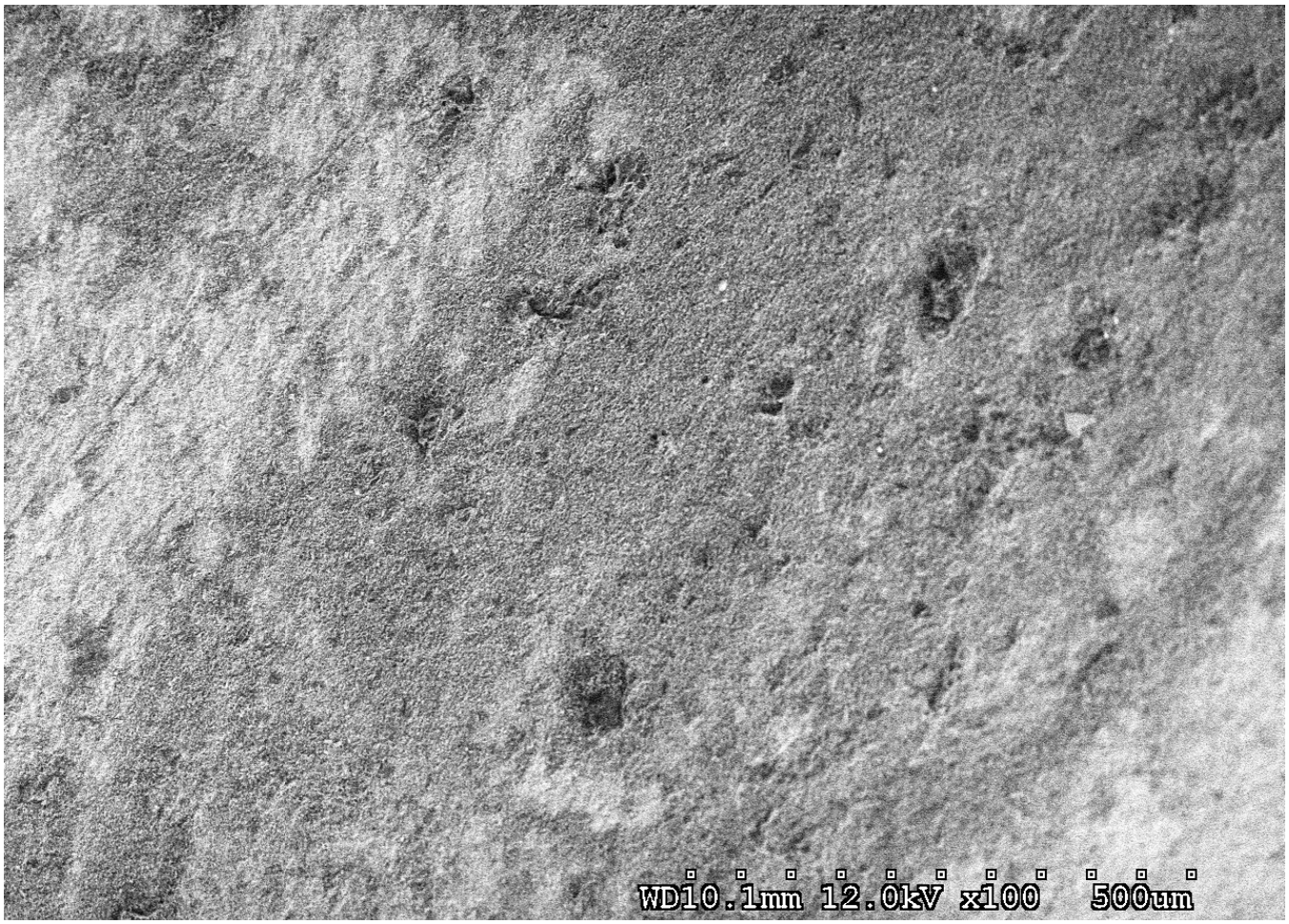

WD10.1mm 12.0kV x350 100um


WD10.1mm 12.0kV x150 200um

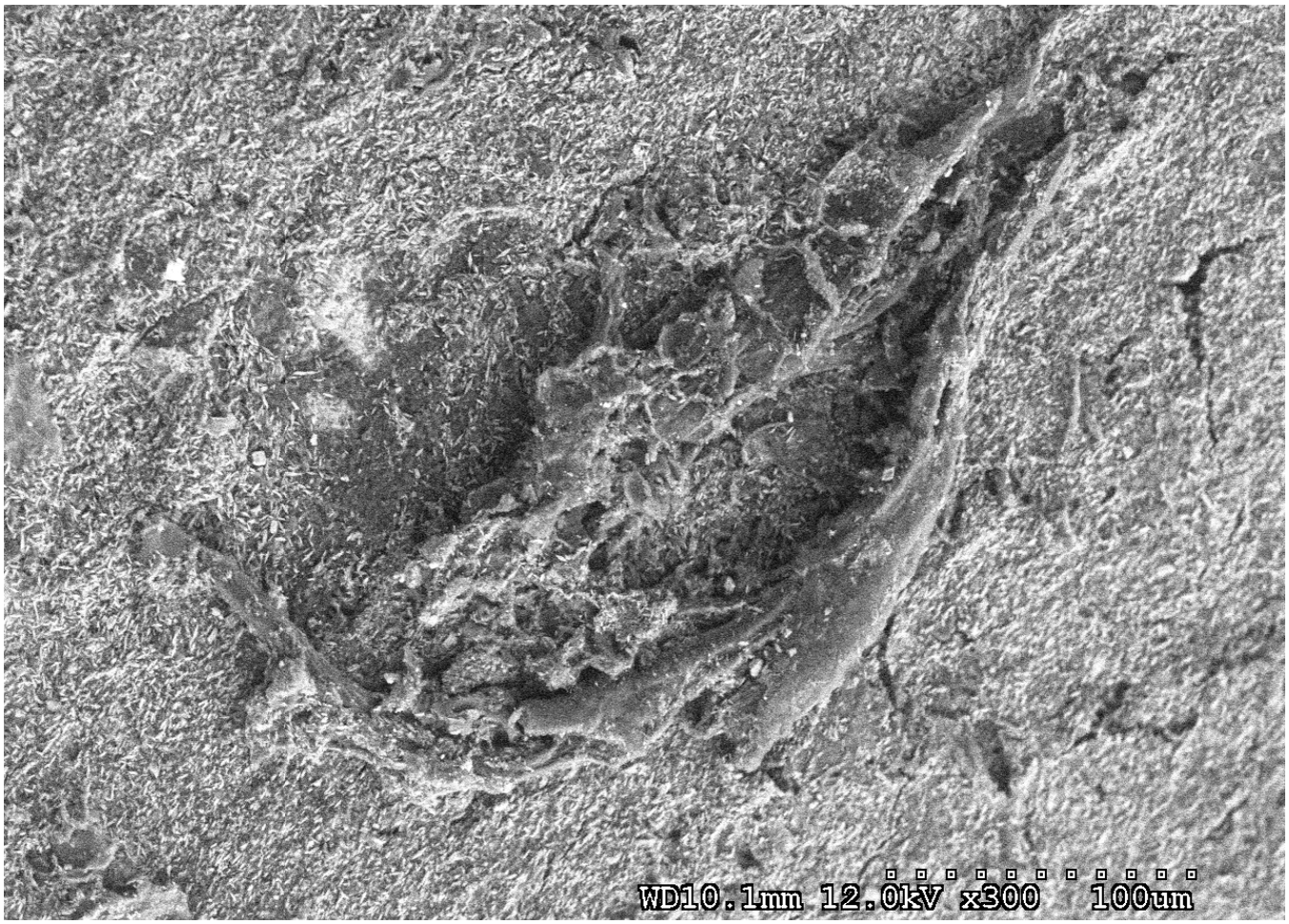

WD10.1mm 12.0kV x700 50um


WD10.1mm 12.0kV x80 500um


WD10.1mm 12.0kV x400 100um


WD10.1mm 12.0kV x100 500um

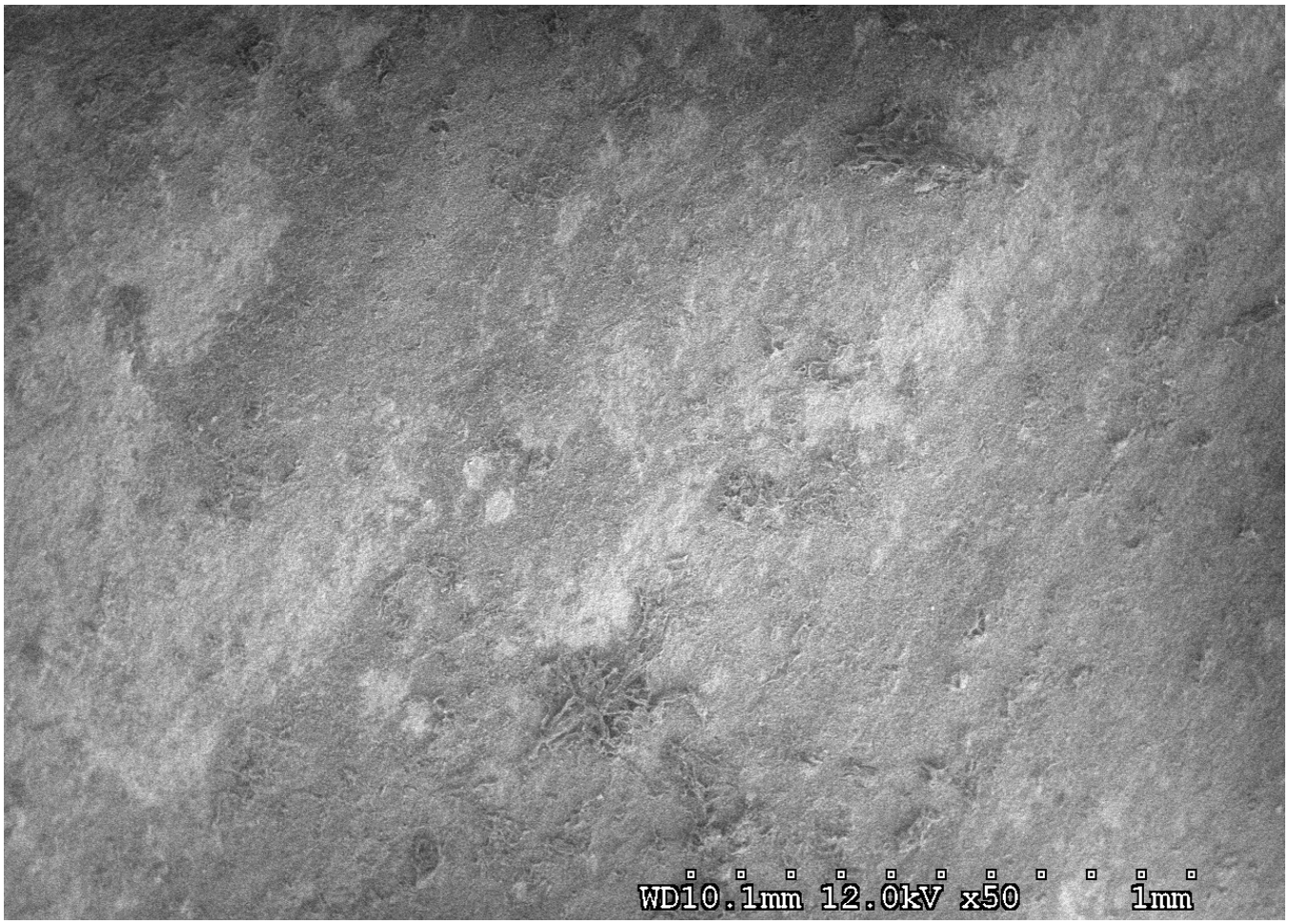
WD10.1mm 12.0kV x700 50um


WD10.1mm 12.0kV x300 100um

WD10.1mm 12.0kV x100 500um

WD10.1mm 12.0kV x50 1mm

WD10.1mm 12.0kV x300 100um


WD10.1mm 12.0kV x50 1mm